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Supplementary Information

3D hierarchical MnO₂ nanorods/welded Ag-nanowire-network composites for high-performance supercapacitor electrodes

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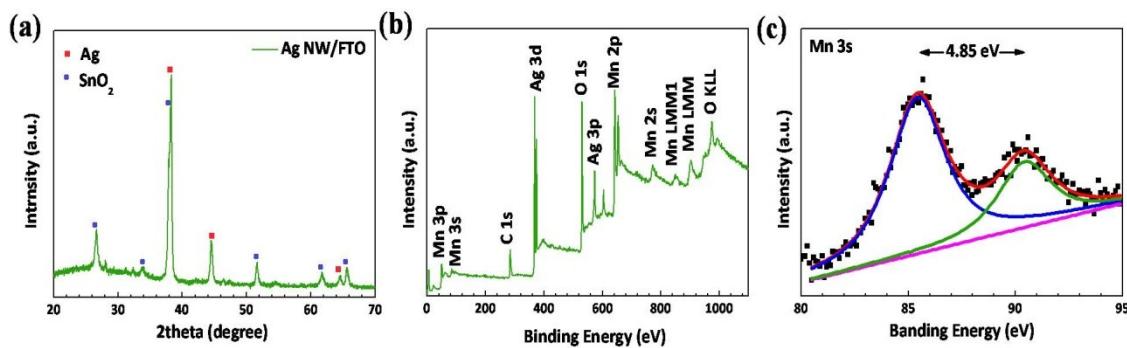


Fig. S1 (a) XRD patterns of the AgNW/FTO. (b) XPS full-survey-scan spectrum of the 3D MN/w-ANN composites, (c) XPS core-level spectra of Mn 3s.

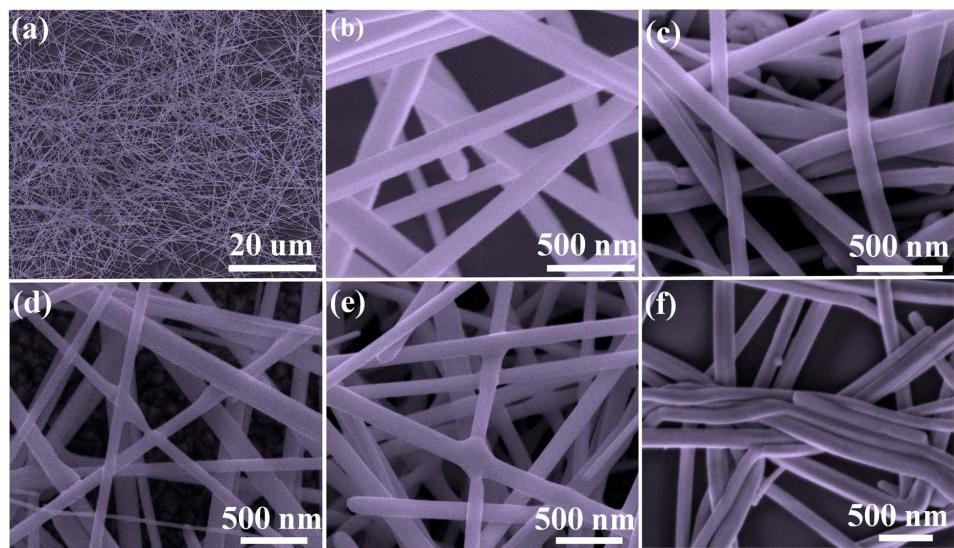


Fig. S2 SEM of AgNW network at different annealing temperature (a) and (b) room temperature; (c) 200 °C; (d) 250 °C ; (e) 300 °C; (f) 350 °C.

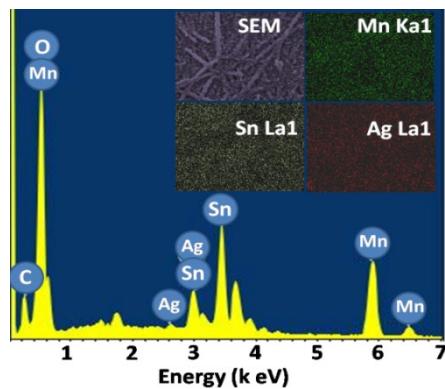


Fig. S3 EDX spectrum showing the elemental composition of the 3D MN/w-ANN composites, the insets show its SEM and elemental mapping of Mn, Sn and Ag.

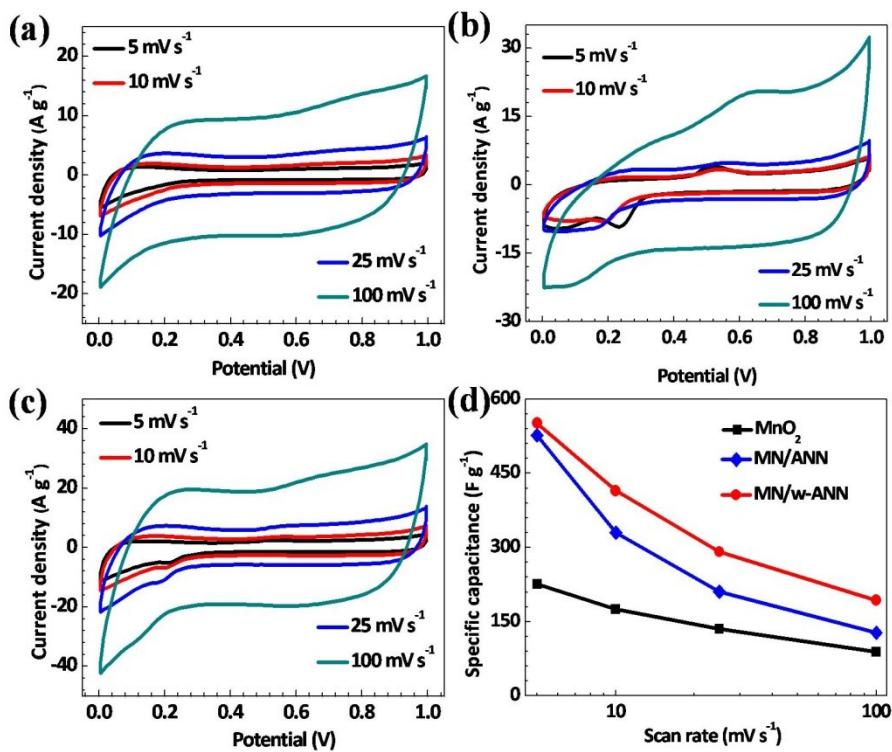


Fig. S4 CV curves for (a) the bare MnO₂, (b) the MN/ANN electrode and (c) the 3D MN/w-ANN composite electrode at different scan rates in 0.5 M Na₂SO₄ aqueous electrolyte; (d) Specific capacitances of the bare MnO₂, the MN/ ANN and the 3D MN/w-ANN composite electrode.

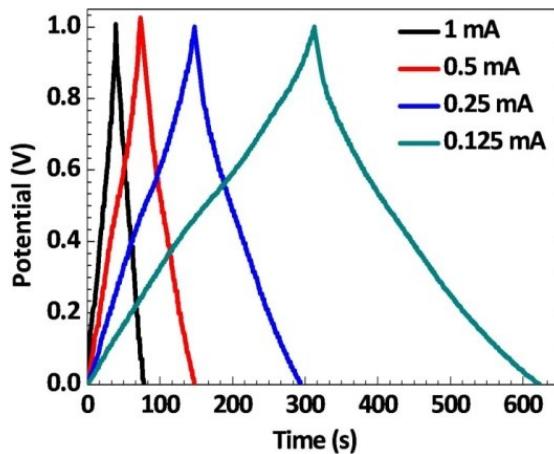


Fig. S5 GCD curves of the 3D MN/w-ANN composite electrode at different current.

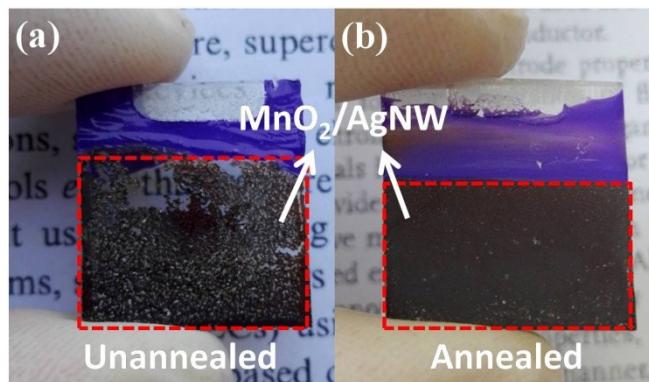


Fig. S6 Photo images of electrodes after GCD testing (a) the MN/ ANN electrode; (b) the 3D MN/w-ANN composite electrode.

Table S1. The mass ratio between MnO_2 and AgNW network in the 3D MN/w-ANN composite electrode s and the corresponding specific capacitance.

AgNWs spin-coated number	0	5	10	20	40	60	80	100
Mass ratio (MnO_2 :AgNW)	1 : 0	1:0.05	1:0.10	1:0.19	1:0.28	1:0.30	1:0.40	1:0.45
Specific capacitance (F g^{-1})	135.1	191.7	218.5	274.3	314.8	354.1	378.3	365.4

Table S2. Comparison of specific capacitance, cycle number and capacitance retention of the reported MnO_2 electrodes and the present work.

Materials	Electrolyte	Testing condition	Specific capacitance	Cycle number	Capacitance retention	Ref.
Mesoporous MnO_2	1 M Na_2SO_4	0.4 A g⁻¹	229 F g^{-1}	2000	97.3%	1
MnO_2 nanowires	0.1 M Na_2SO_4	77 mA g ⁻¹	167.5 F g^{-1}	3000	88%	2
MnO_2 nanorod arrays	0.5 M Na_2SO_4	3 A g⁻¹	485.2 F g^{-1}	1500	123 %	3
Free-standing MnO_2 nanorods	0.5 M Na_2SO_4	3 A g⁻¹	355.7 F g^{-1}	1500	115%	3
MnO_2 /CNTs	1 M Na_2SO_4	1 A g⁻¹	201 F g^{-1}	10000	100%	4
MnO_2 @polyaniline	1 M Na_2SO_4	1 A g⁻¹	437 F g^{-1}	3000	100%	5
ZnO @ MnO_2 core-shell arrays	1 M Na_2SO_4	0.5 A g ⁻¹	423.5 F g^{-1}	3000	92%	6
Ag NP/ MnO_2	1 M Na_2SO_4	10 mV s ⁻¹	272 F g^{-1}	—	—	7
Ag/ MnO_2 /RGO	3 M KOH	5 mV s ⁻¹	126.2 F g^{-1}	1000	134%	8
Ag/PANI/ MnO_2	1 M Na_2SO_4	0.1 A g⁻¹	518 F g^{-1}	1600	88.4%	9

Ag-doped MnO ₂	0.5 M Na ₂ SO ₄	2 mV s ⁻¹	770 F g ⁻¹	—	—	10
Hair-like Ag/MnO _x	1 M Na ₂ SO ₄	2 A g⁻¹	237 F g ⁻¹	800	78%	11
Ag/MnO ₂ hybrid electrode	1 M Na ₂ SO ₄	10 mV s ⁻¹	293 F g ⁻¹	5000	92.5%	12
MnO₂/a-AgNW	0.5 M Na₂SO₄	6 A g⁻¹	663.4 F g⁻¹	7000	157%	The work

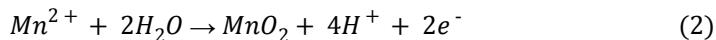
Loading mass calculation of AgNW network and MnO₂

The AgNW/FTO substrates are obtained by spin-coating AgNW ink on FTO conducting glass. Firstly, we weight 20 pieces of cleaned FTO conducting glass with cut into 2*2 cm², and the mass is denoted as m_1 . Then, AgNWs ink is spun on the surface of total FTO substrates at a 3000 rpm rotation speed for 5 times, respectively. Finally, the total AgNW/FTO substrates are weighted, and their loading mass is m_2 . Thus, the mass m^* of each AgNW network layer on FTO can be calculated by equation (1):

$$m^* = \frac{m_2 - m_1}{20} \quad (1)$$

Loading mass of the other AgNW network layer by different spin-coating number can be obtained using the above method.

The electrochemical deposition process was carried out via the potentiostatic method under 1.0 V. And assuming 100% current efficiency via the reaction, shown as follows:



Thus, the loading mass of electrodeposited MnO₂ is calculated using below equation:

$$m^* = \frac{(\int Idt)M}{2eN_A} \quad (3)$$

where I is the current, t is the electrochemical deposition time, m is the electrochemical deposition mass of MnO₂ on the AgNW/FTO substrate, e is the electron charge, N_A is the Avogadro's number, and M is molar mass of MnO₂ (86.9 g mol⁻¹).¹² Therefore, the loading mass of MnO₂ on the AgNW/FTO substrate is around 0.30 mg.

Specific capacitance calculation of MnO₂/a-AgNW electrode

Specific capacitance (C_{sp}) is the capacitance per unit mass for one electrode. In Cyclic voltammetry

(CV) measurements, the C_{sp} is calculated from:

$$C_{sp} = \frac{\int I dV}{2m\Delta V v_0} \quad (4)$$

where I is the current, V is the voltage, ΔV is the voltage window, v_0 is the scan rate, and m is the loading mass of MnO_2 .

In galvanostatic charge/discharge (GCD) measurements, the C_{sp} is calculated from:

$$C_{sp} = \frac{I \Delta t}{m\Delta V} \quad (5)$$

where I is the discharge current, Δt is the discharge time, the ΔV is the voltage difference of discharge, and m is the loading mass of MnO_2 .¹³

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